

# First Measurements with the APS Optical Slope Measuring System (OSMS)

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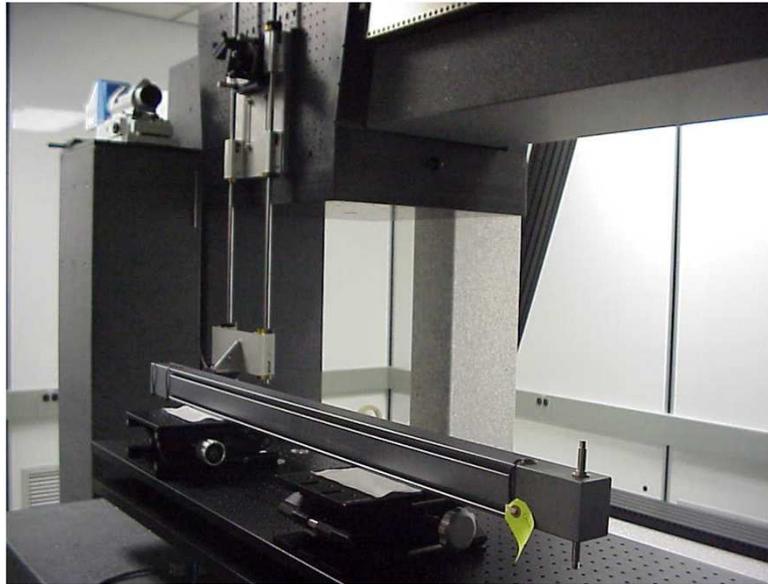
# Outline

- The development of the APS-LTP-II / APS-OSMS
- The APS OSMS / flat mirror measurement
  - Alignment
  - Repeatability test
  - Systematic error test
  - Reliability test
- Elliptical KB mirror measurements (APS OSMS, APS LTP-II, APS Stitching)
- Conclusion
- Acknowledgements



## The APS OSMS and the APS LTP-II

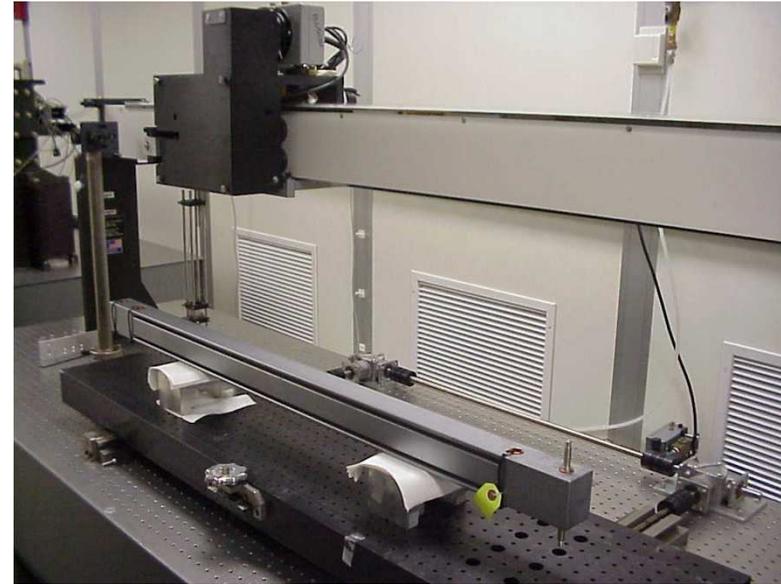
The APS OSMS (2012)



Slope accuracy: Phase I < 100 nrad  
Phase II < 50 nrad

The APS OSMS (See talk by Lahsen Assoufid et al, this workshop).

The APS LTP-II (1999)

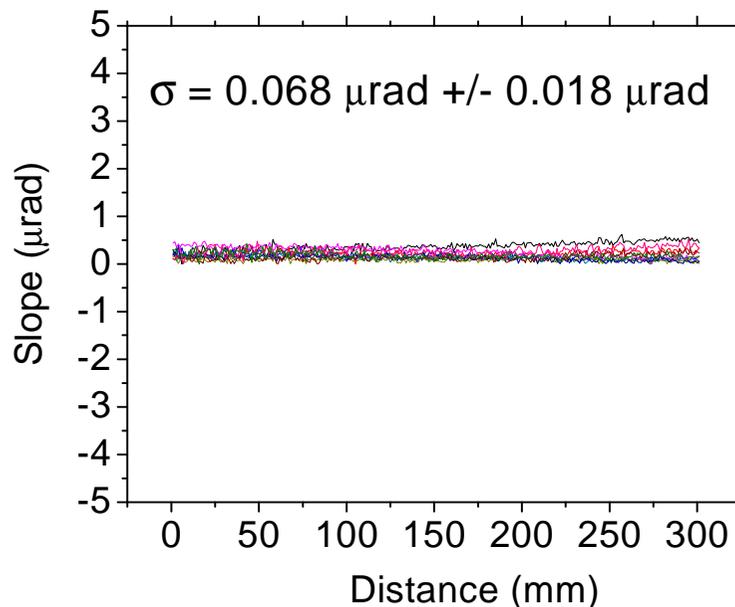


Slope accuracy: RMS=0.3  $\mu$ rad

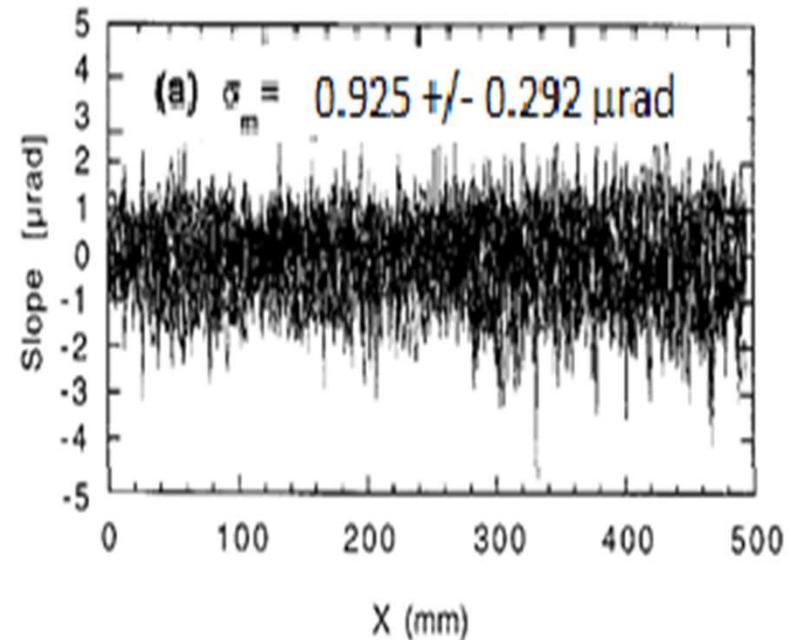
P.Z. Takacs, E.L. Church, C. Bresloff, and L. Assoufid, Appl. Optics, 38,(25) (1999), 5468-5479.

## Comparison of the repeatability measurement results acquired with the APS OSMS (2012) and the LTP-II (1999)

- Method:
1. Performed 10 scans in same conditions.
  2. Found the deviation of the single scan - the average of the 10 scans.
  3. Calculated the average of the rms of the 10 deviation profiles.



2012 with the APS OSMS  
Mirror: 350 mm Si substrate



1999 with the APS LTP-II  
Mirror: 500 mm Si substrate

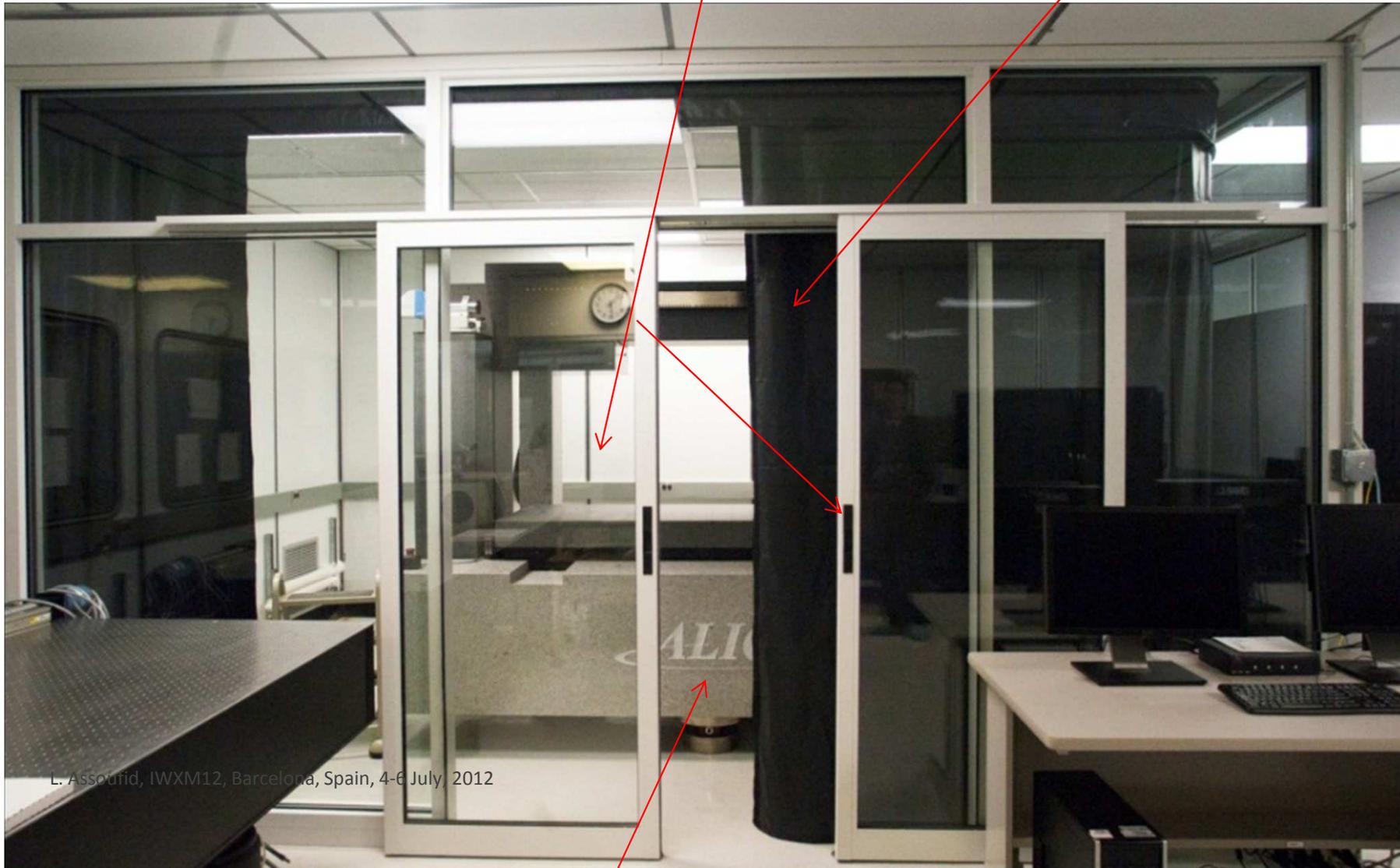
P.Z. Takacs, E.L. Church, C. Bresloff, and L. Assoufid, Appl. Optics, 38,(25) (1999), 5468-5479.

# Enclosure

Completed November 2011

Laser curtain/visible light shield

Double sliding doors

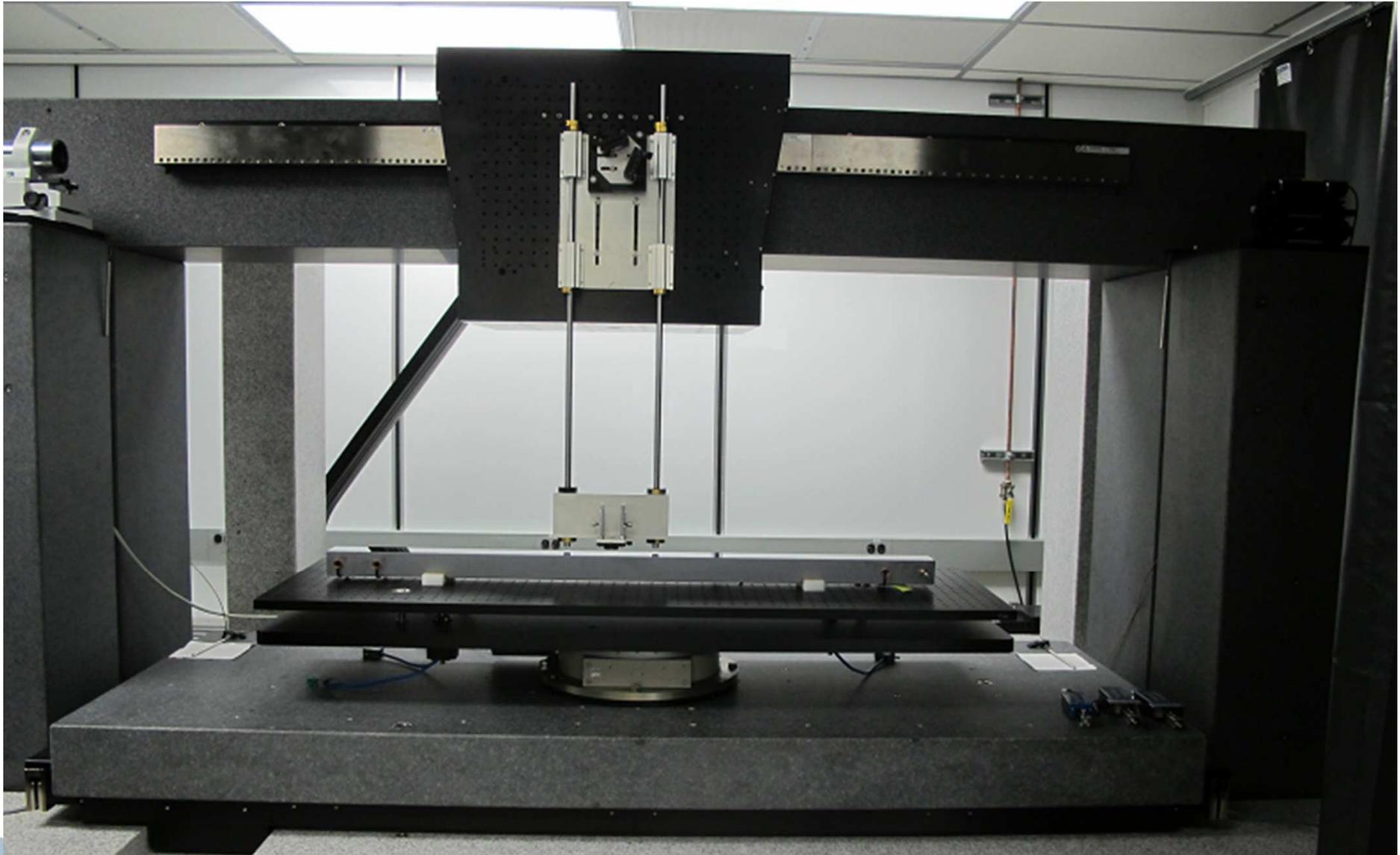


L. Assoufid, IWXM12, Barcelona, Spain, 4-6 July, 2012

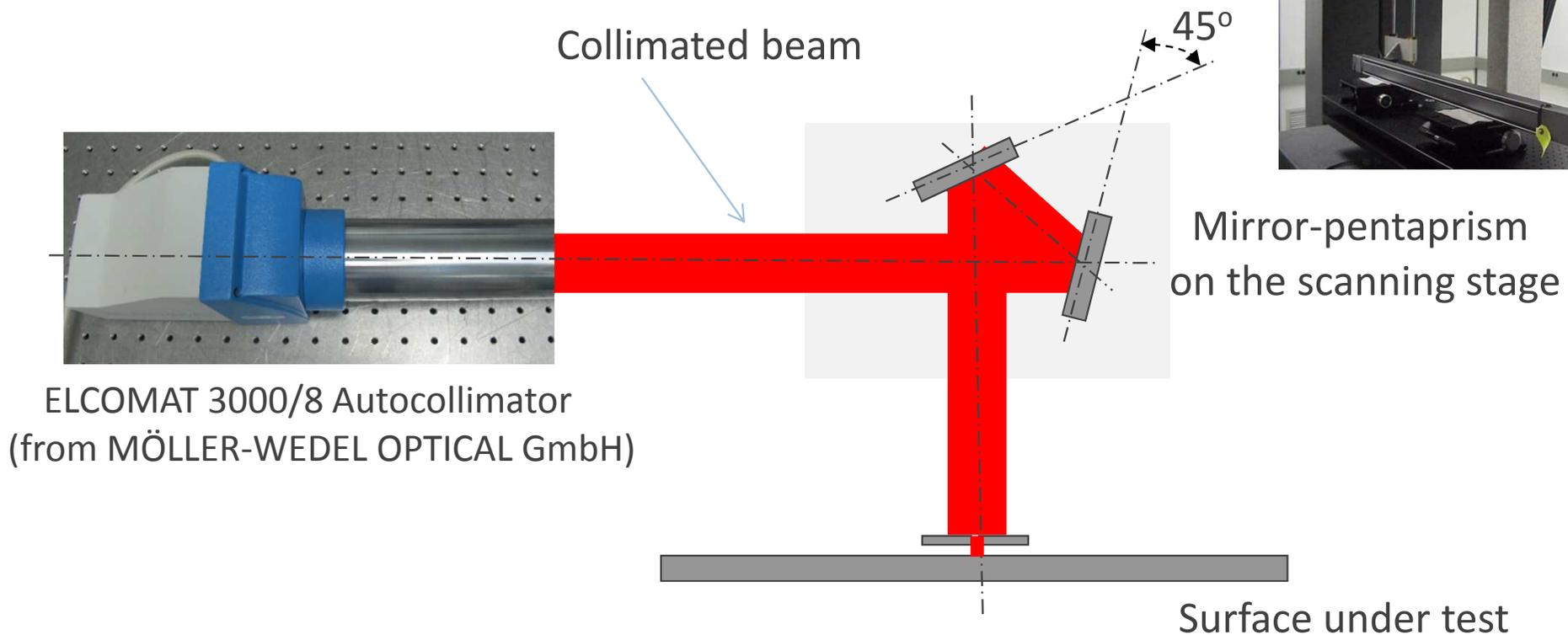
Granite table



# The APS Optical Slope Measuring System



# The optics system of the APS OSMS



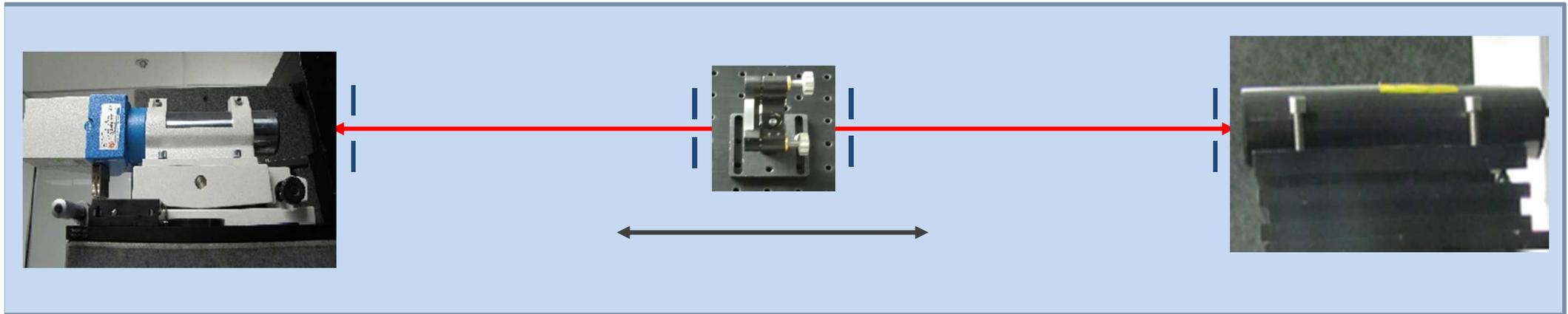
To align the OSMS properly for achieving high accuracy:

1. The axis of the autocollimator should be parallel to the axis of the scanning stage.
2. The beam shouldn't be twisted; needs to minimize roll, pitch, and yaw errors of individual optic.

\*F. Siewert, H. Lammert, T. Zeschke, Modern Developments in X-ray and Neutron Optics, Springer 2008

\*S. G. Alcock and K. J. S. Sawhney, Proc. SPIE 6704, 67040E (2007).

## Alignment of the autocollimator parallel to the scanning stage



Fixed Autocollimator

Mirror with polished backside on scanning stage

Fixed He-Ne Laser

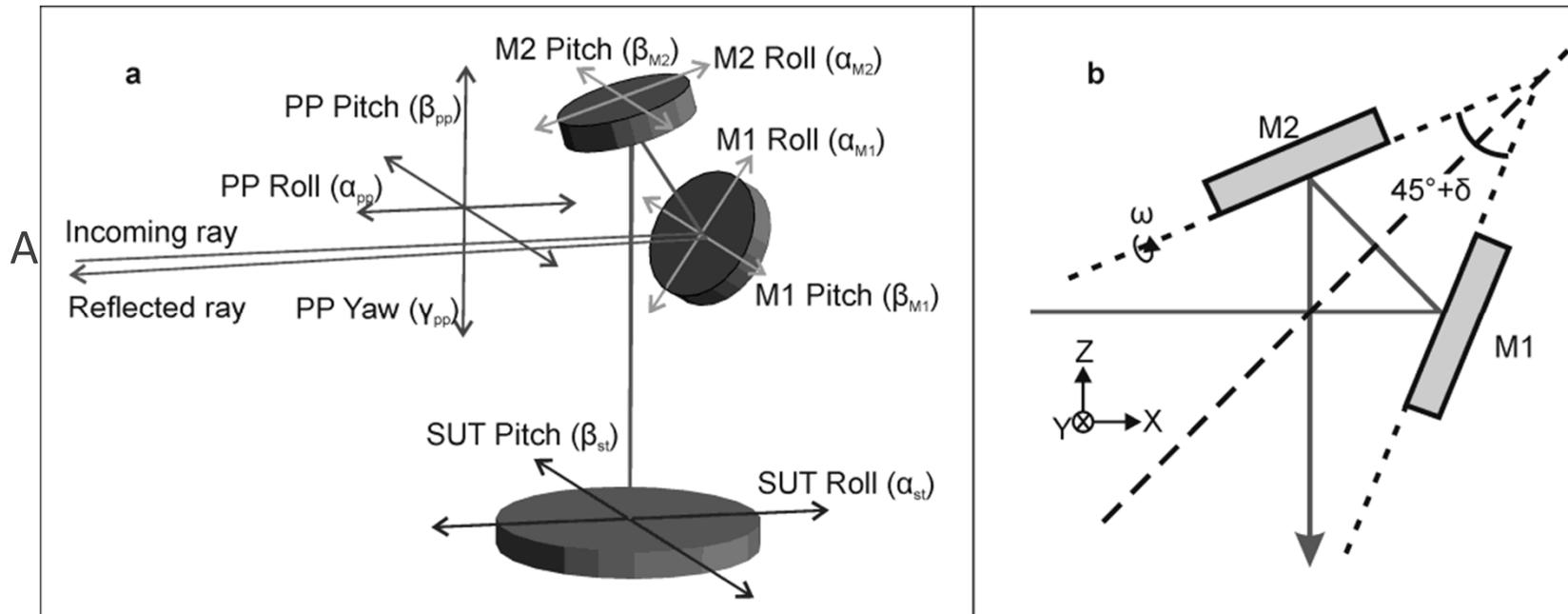
Procedure of the alignment:

- 1: Align the laser // scanning stage with the help of the pinholes -> fix the laser
- 2: Align the mirror relative to the laser -> fix the mirror
- 3: Align the autocollimator relative to the mirror -> fix the autocollimator
4. Take measurement while scanning the mirror and then make fine corrections.

**Goal: Autocollimator axis // to the axis of the scanning stage**



# Alignment of the mirror pentaprism relative to the SUT



Individual mirror: roll and pitch errors  
 Pentaprism unit: roll, pitch and yaw errors

M1 / M2 Parallel error  
 M1 / M2 45° angular error

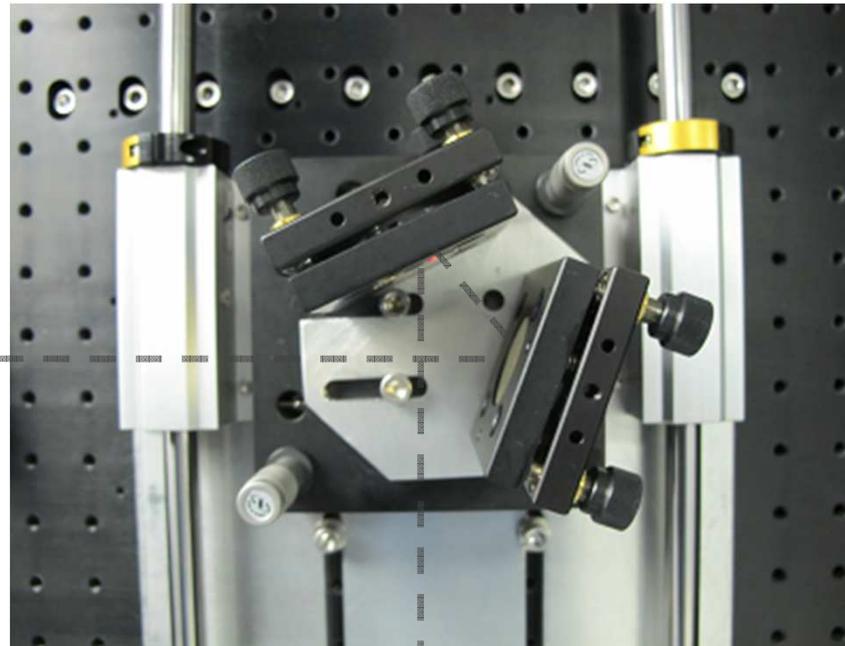
R. D. Geckeler, *Meas. Sci. Technol.* **18** 115-125 (2007).

Samuel K Barber, et al., *Optical Engineering* Vol. 50(5), May 2011

## The mirror pentaprism design

- Individual mirror is on itself x-y axes adjustable mirror mount.
- Both mirror mounts are on the x y axes adjustable and rotatable mirror mount to form the mirror pentaprism unit.

Fixed autocollimator



SUT

Mirror pentaprism unit: roll, pitch and yaw errors  
Need more careful alignment

Method: trail - and - error

## Optimizing measurement conditions

- Stability scan with enclosure close/open
- Stability scan with local air on/off
- Stability scan with a fixed mirror setting at different locations relative to the autocollimator
- Stability scan with a fixed mirror on moving stage
- Different size of aperture
- Sampling rate per data point
- Scan w/o delay after each data collection
- Orientation of the autocollimator (x\_axis / y\_axis)

**Finding optimal measurement conditions is essential to achieve the desired performance!**

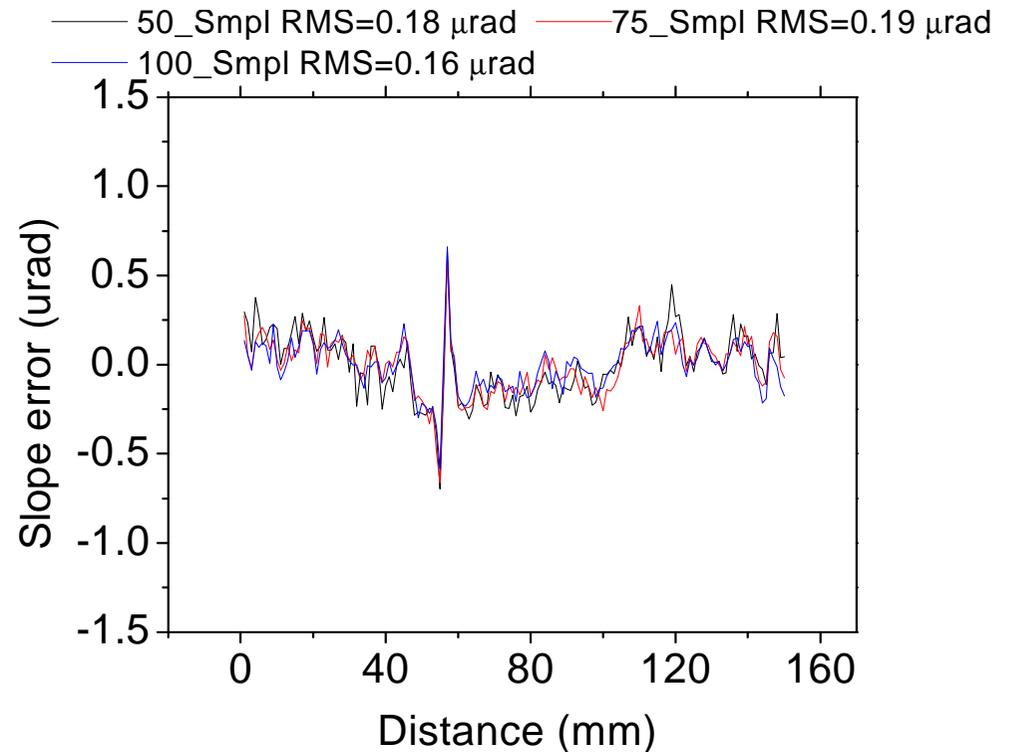
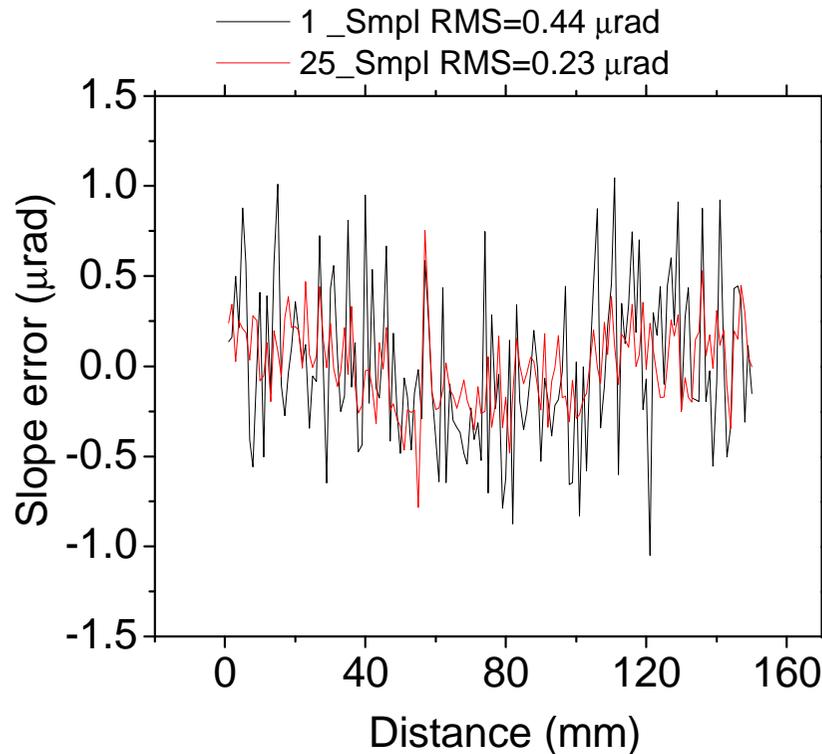


## Example

### How about sampling rate at each data point?

Sampling rate: # of samples per data point taken in the measurement.

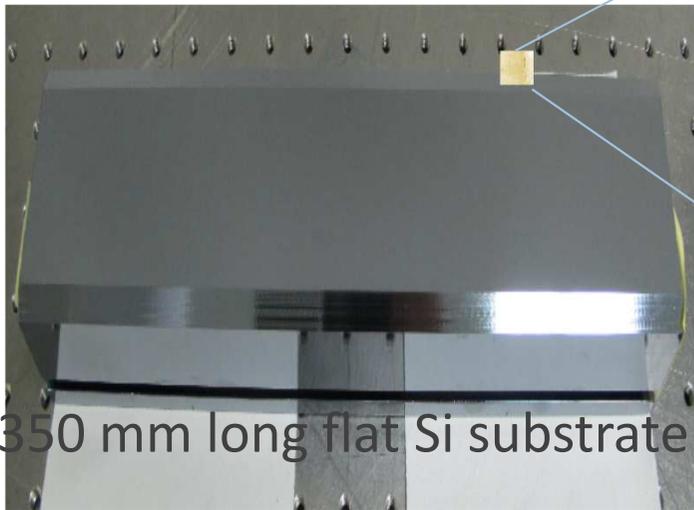
We tried measurements with samples of 1, 25, 50, 75 and 100 per data point to see the difference of the S/N.



**We decided from now on, we use sampling rate of 50/point for all of the normal measurements.**



**First mirror measurement with the APS OSMS was carried out in January 2012.**



350 mm long flat Si substrate



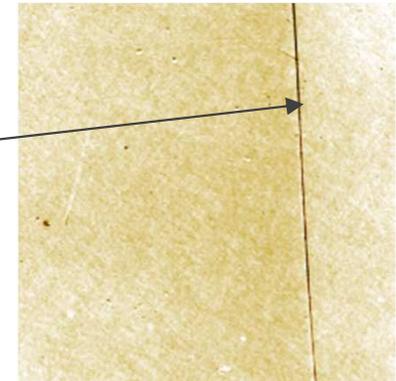
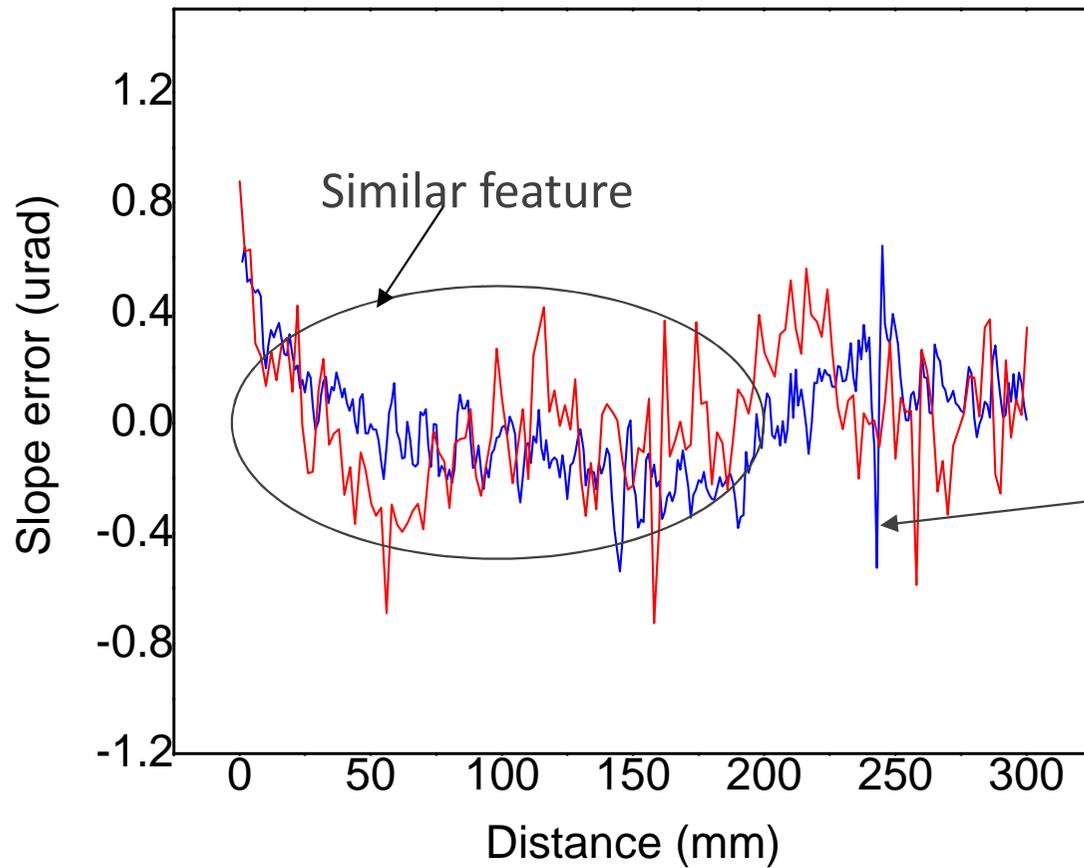
Defect on surface  
(Identity)



MicroXAM  
surface profiler

## Data comparison of the 350 mm long flat mirror acquired with the OSMS and LTP-II

- OSMS slope error: RMS=0.20  $\mu\text{rad}$  (well shaped, high S/N)
- LTP-II slope error: RMS=0.30  $\mu\text{rad}$  (very noisy)



# Systematic error of the APS OSMS < 70 nrad

(Method: Making forward and backward scans and comparing the profiles)

forward scans



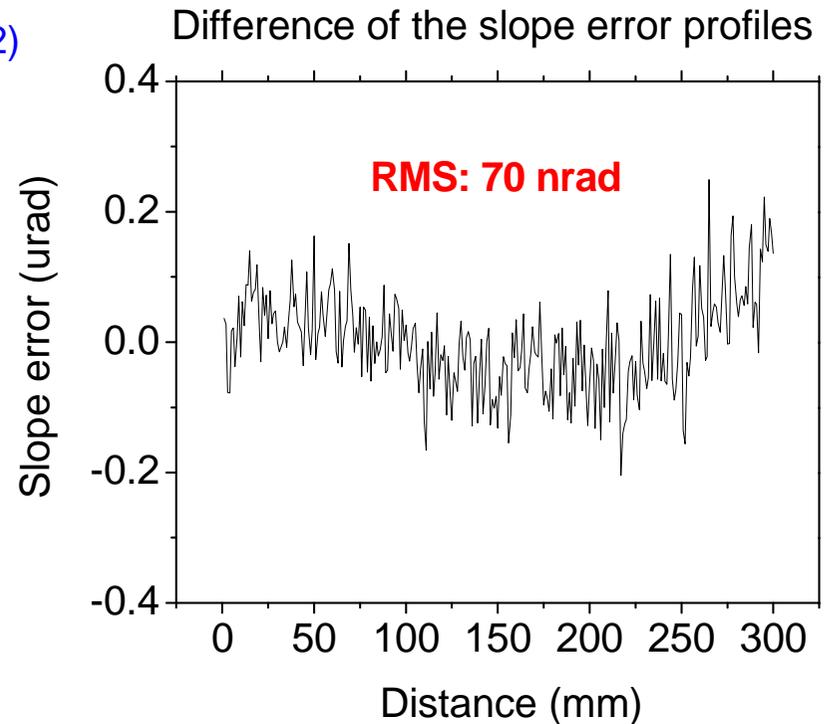
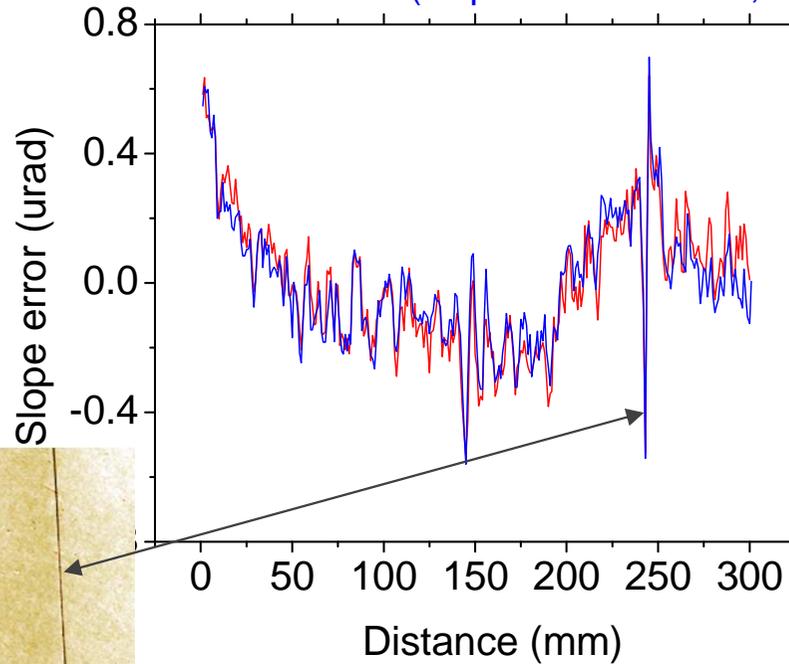
Scan direction

Measured in two different days

backward scans

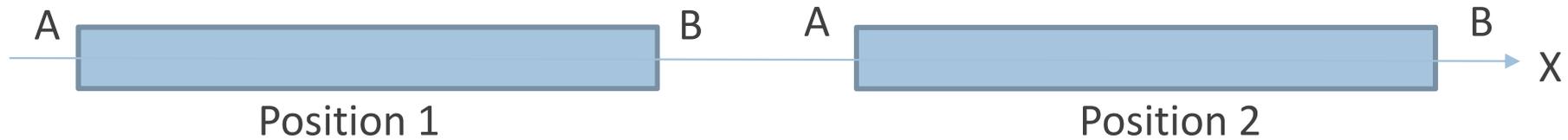


- Forward scan (slope err: 0.20 urad, 1/5/2012)
- Backward scan (slope err: 0.19 urad, 1/11/2012)



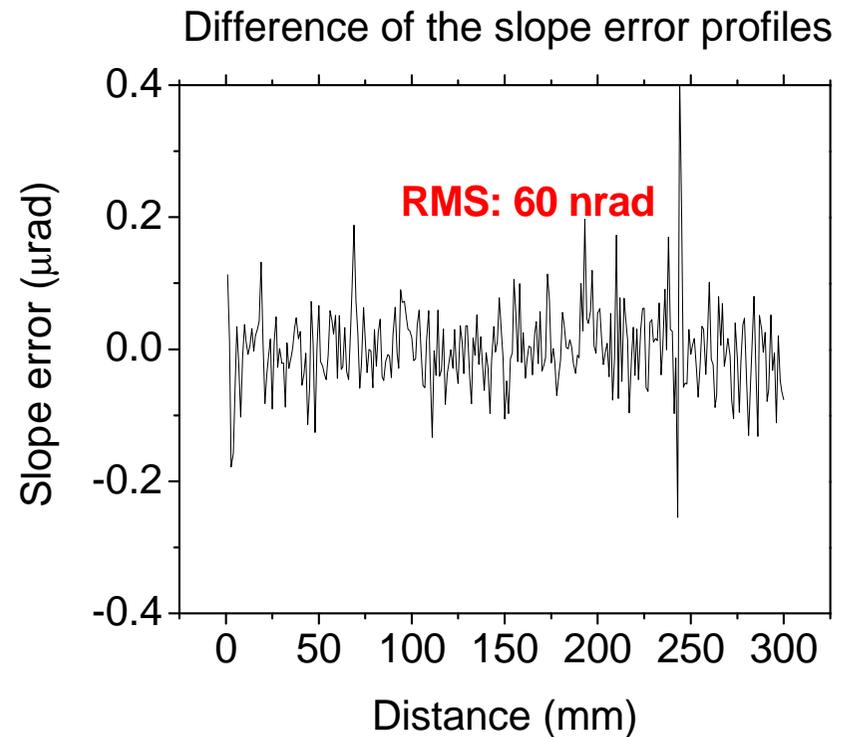
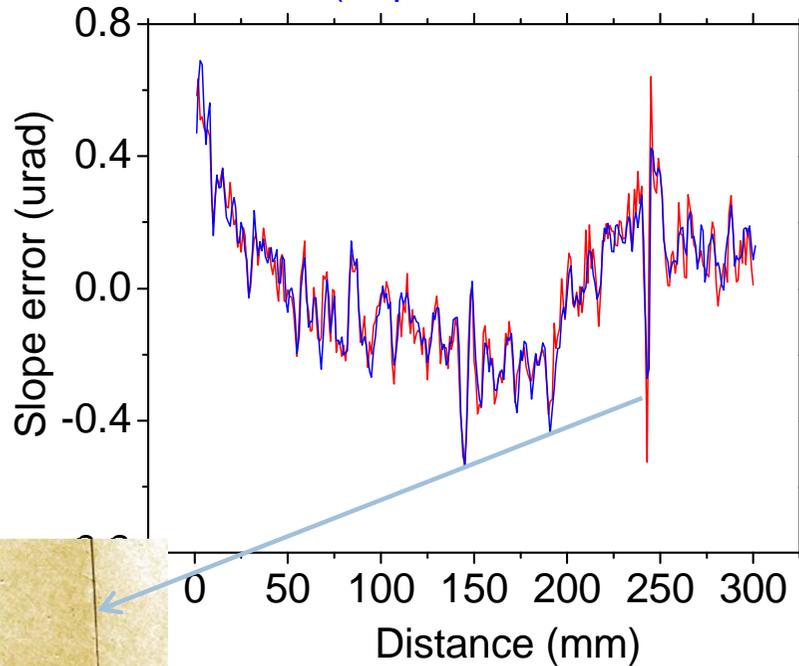
# Reliability of the APS OSMS < 60 nrad

(Method: taking measurements with mirror at different locations)



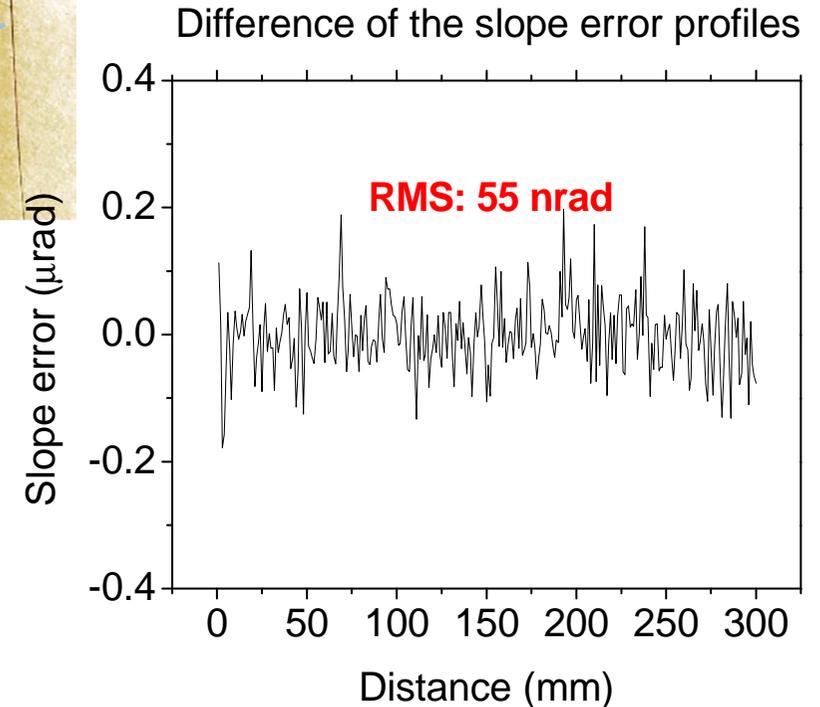
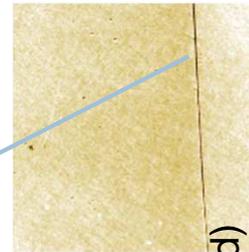
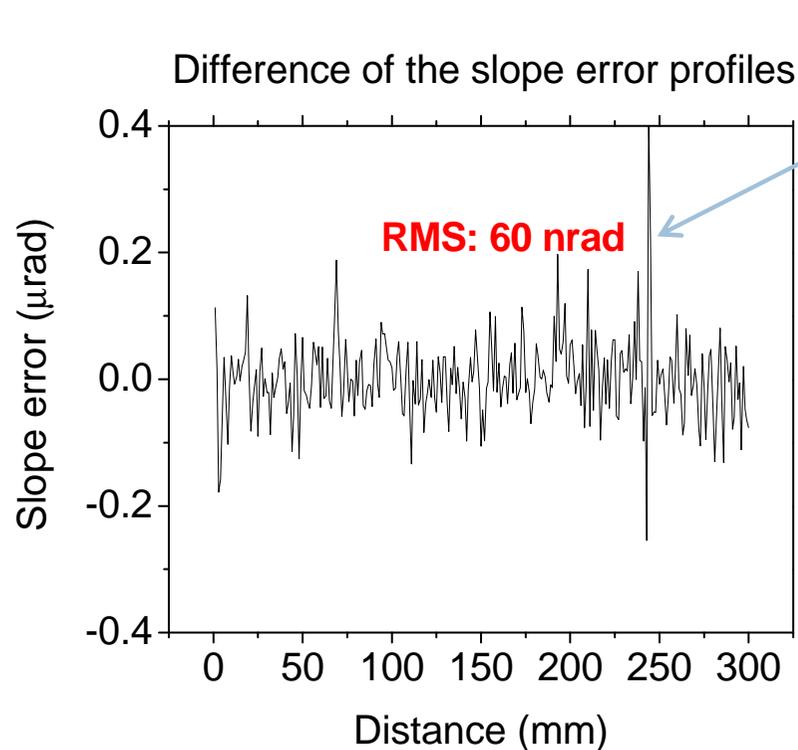
Measured in two different days!

- Forward scan (slope err: 0.20 urad, 1/5/2012)
- Forward scan (slope err: 0.20 urad, 1/13/2012)



**Measurements reliable and repeatable!**

# Is it possible to achieve less than 60 nrad rms?



~0.1 mm difference



Most likely it is due to mirror positioning error in the two measurements

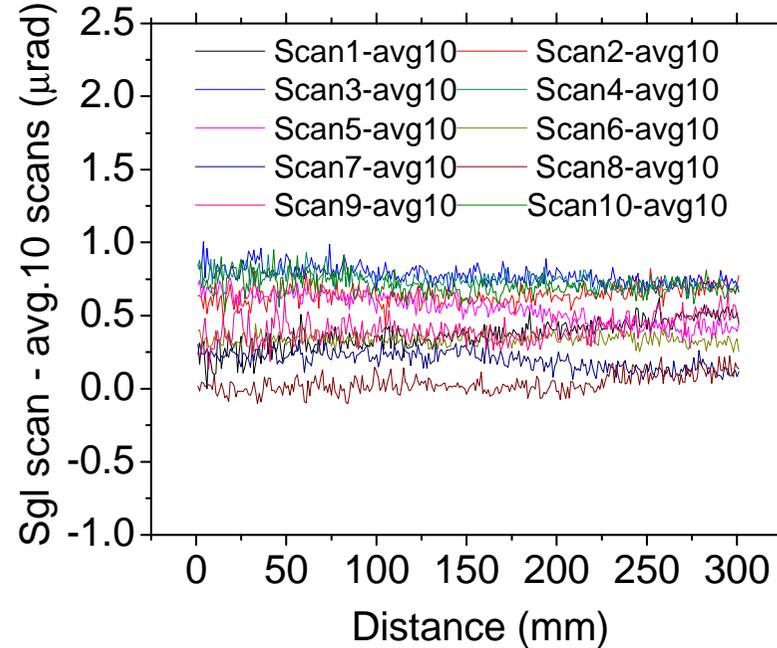
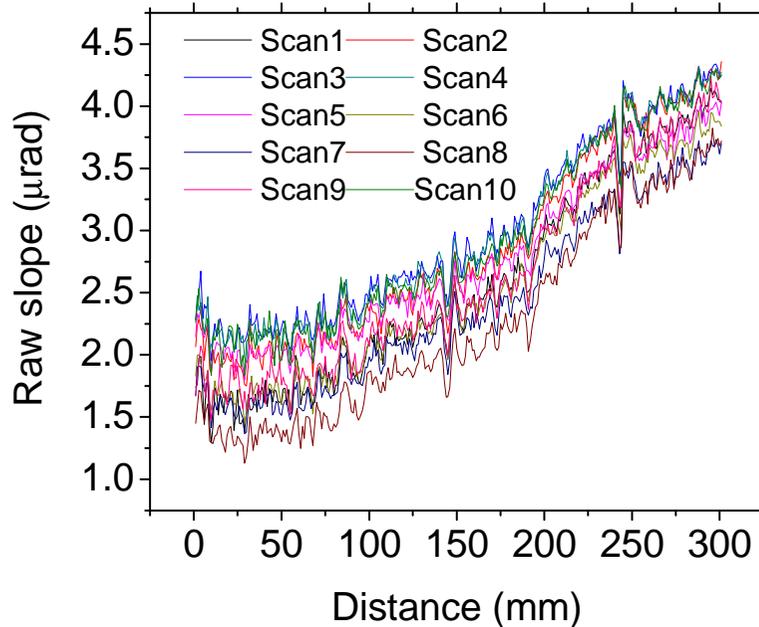
Manually removed the big spike

Further work

1. Positioning the mirror precisely.
2. Make measurement steps smaller. (Steps of the current data: 1 mm.)

# Repeatability of the APS OSMS ~ 97.50%

(Method: Comparing 10 forward scans)



Scan	RMS of the raw slope (µrad)	Profile subtraction	RMS of the Slope Diff (µrad)
1	2.8527	Scan 1 - avg	0.0979
2	2.9849	Scan 2 - avg	0.0589
3	2.9560	Scan 3 - avg	0.0614
4	2.7562	Scan 4 - avg	0.0512
5	2.5456	Scan 5 - avg	0.0999
6	2.4062	Scan 6 - avg	0.0363
7	2.244	Scan 7 - avg	0.0617
8	2.6164	Scan 8 - avg	0.0635
9	2.9154	Scan 9 - avg	0.0832
10	2.869	Scan 10 - avg	0.0670
<b>Average</b>	<b>2.7146+/-0.0401</b>	<b>Average</b>	<b>0.0682+/-0.0185</b>

Deviation of the single scan  
to  
the average of 10 scans

**Ratio**  
**of the slope-diff to raw slope**  
**0.0682 / 2.7146 = 0.0251 !**

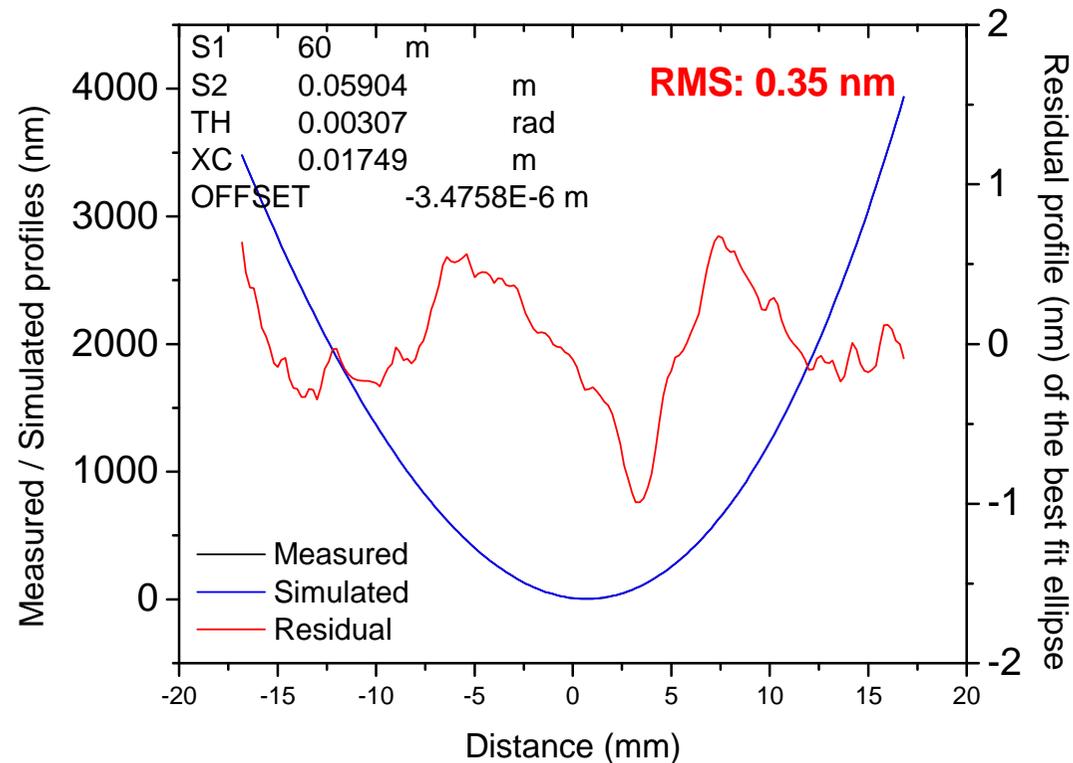


# Measurement of an elliptical KB mirror for APS 34 ID beamline

Size: 40mm x 20mm x 20mm

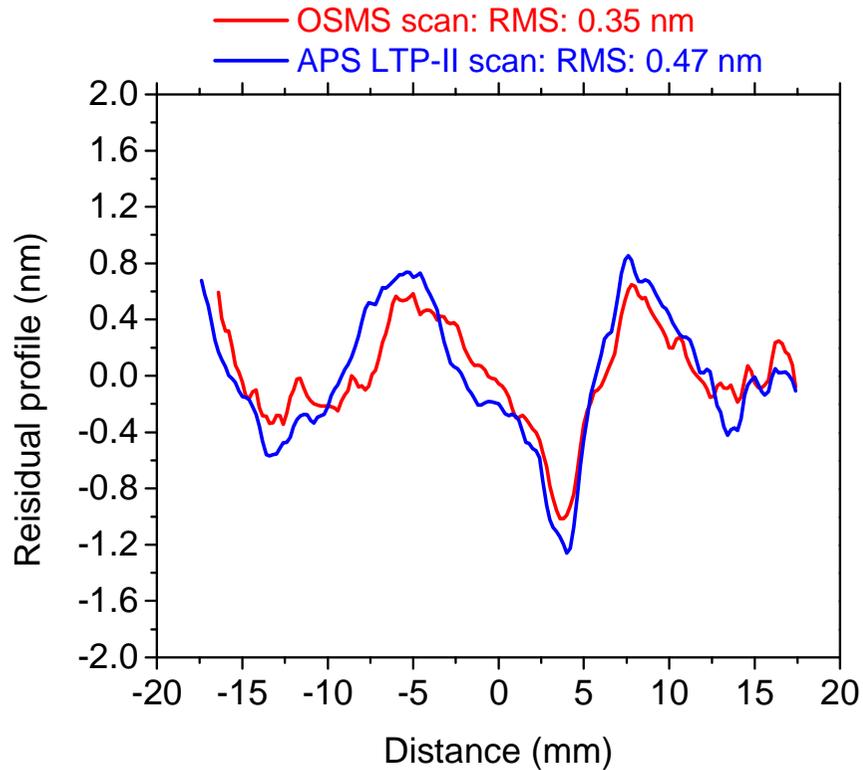
Shape: Elliptical (S1=60 m, S2=60 mm, Theta= 3 mrad, mean curvature: ~40 m)

Instrument: APS OSMS, APS LTP-II and APS MicroXAM surface profiler (stitching)

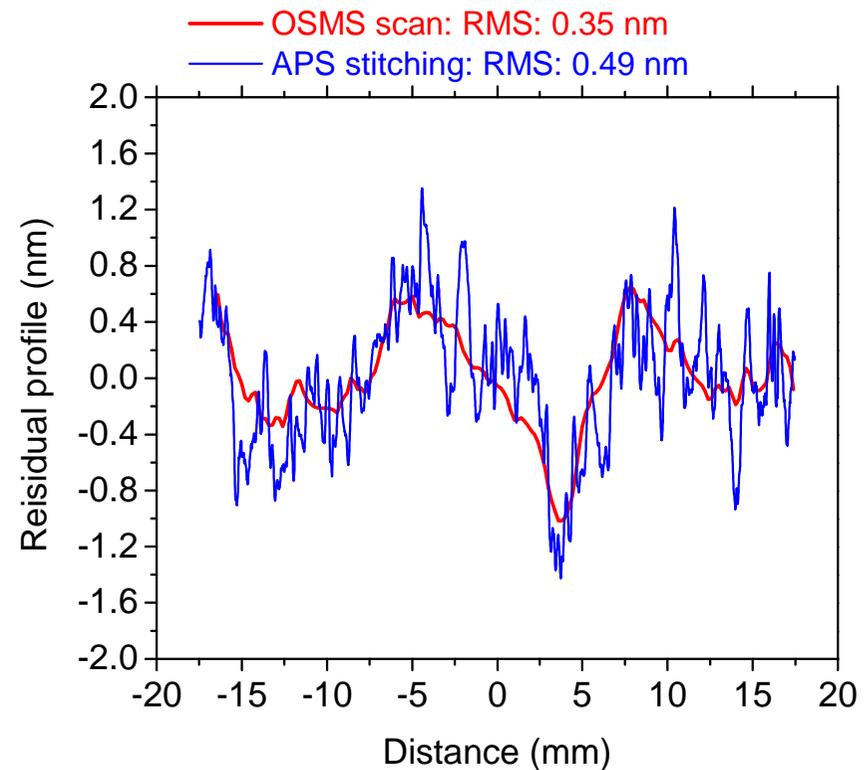


Simulation result (best fit ellipse) of the KB mirror height profile acquired with the APS OSMS

# Residual profiles of the best ellipse fit of the KB mirrors data acquired with the OSMS, LTP-II and Stitching profiler



Data comparison  
APS OSMS vs. APS LTP-II



Data comparison  
APS OSMS vs. APS Stitching

## Conclusion

1. We performed the preliminary tests of the APS OSMS for super flat mirrors and achieved our Phase I goal for  $< 100$  nrad rms slope error system accuracy.

Data summary:

- Systematic error  $< 70$  nrad
- Reliability error  $< 60$  nrad
- Repeatability error  $< 68$  nrad  
or the repeatability  $\sim 97.5\%$

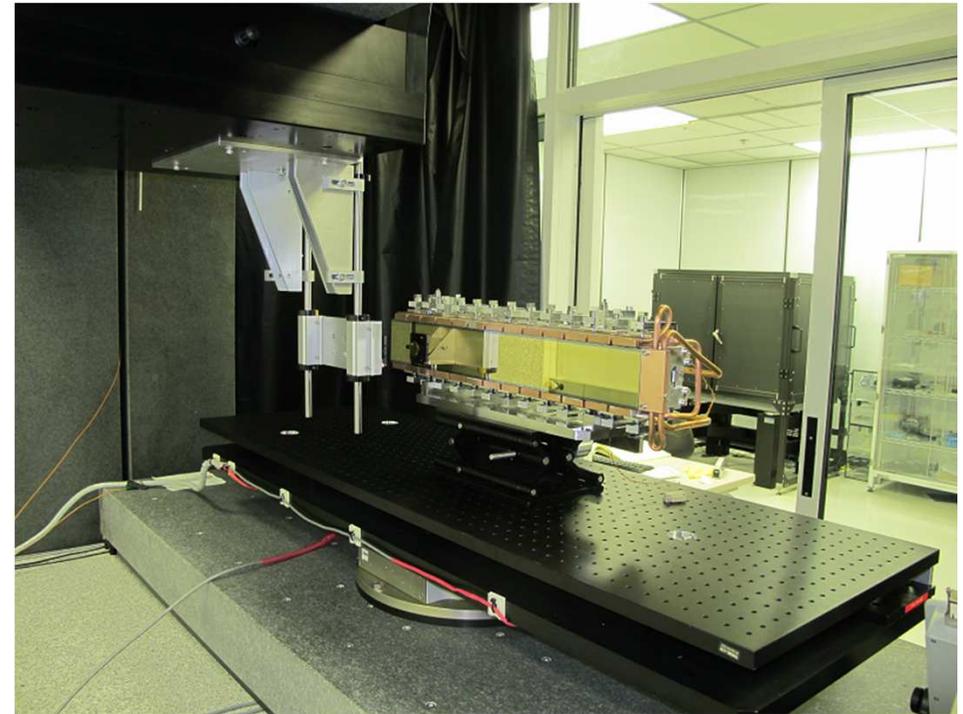
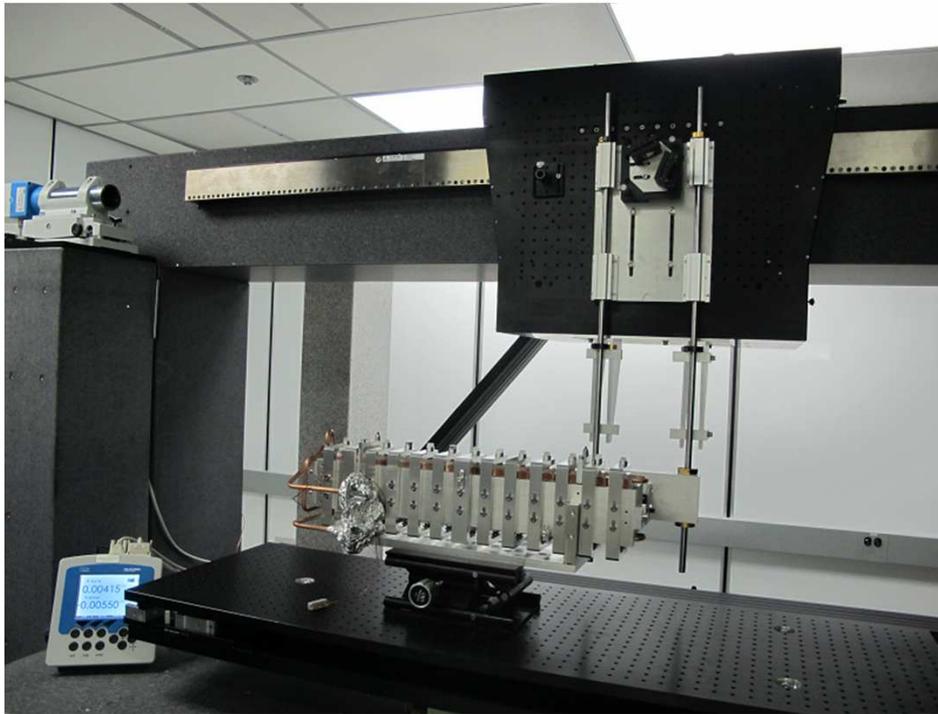
2. For curved KB mirror measurement, the APS OSMS data agrees with the data from the APS LTP-II and APS stitching interferometer.

3. Further works:

- Curved mirror/correction with the calibration data of the autocollimator
- Further measurement to evaluate performance
- Environment control, software development



The APS OSMS has been joining the other instruments for measuring mirrors for APS users.



600 mm long clamped HFM for high heat load exp. , 29ID IEX beamline in the APS

**Mirror was facing sideway.  
Measurements were performed on June 29, 2012**



## Acknowledgements

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**Thanks for your attention!**

